



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re:

Tatarka, et al.

Appl. No.:

09/431,931

Filed: For:

November 1, 1999

PUNCTURE RESISTANT, HIGH SHRINK FILMS,

BLENDS, AND PROCESS

November 20, 2001

Group Art Unit: 1773

Examiner: M. Jackson

Commissioner for Patents Washington, DC 20231

AMENDMENT UNDER 37 C.F.R. §1.111

Sir:

In reply to the Official Action dated May 22, 2001, for which a three (3) month extension of time is requested, making the deadline for reply November 23, 2001 (November 22, 2001 being a Holiday), please amend the application as follows.

In The Specification:

Please revise Page 68, last paragraph, , beginning on line 18 through Page

follows:

In The Specification:

In another aspect of the invention, one or more alternative layers having gas barrier properties may be incorporated into a multilayer film as either an intermediate or surface layer or both. For example, ethylene vinyl alcohol copolymer (EVOH), vinylidene chloride-methylacrylate copolymer, nylon such as nylon 6 or amorphous nylon, polyvinylidene chloride-vinyl chloride copolymer (pvdc), acrylonitriles and other materials having oxygen barrier properties may be used in one or more layers such as the core layer. Blends of resins having gas barrier properties may also be used e.g. a blend of nylon with EVOH. Typical gas barrier films will have an O₂ transmission of less than 15 cc/100 in² for 24 hrs. at 1 atm.. In various multilayer embodiments of the invention well known adhesive resins such as